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APPLICATION NO.	F	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/604,060	10/604,060 06/24/2003		Richard A. Conti	FIS920030135US1	1059	
29371	29371 7590 03/01/2004				EXAMINER	
CANTOR			ROCCHEGIANI, RENZO			
55 GRIFFIN			ART UNIT	DADED MUMBER		
BLOOMFIE	LD, CT	06002	ARTONII	PAPER NUMBER		
			2825			

DATE MAILED: 03/01/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

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		Application No.	Applicant(s)					
Office Action Summary		10/604,060	CONTI ET AL.					
		Examiner	Art Unit					
		Renzo N. Rocchegiani	2825					
	The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply							
A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).								
Status								
1)⊠	Responsive to communication(s) filed on <u>24 June 2003</u> .							
2a) <u></u> ☐	This action is FINAL . 2b)⊠ Th	action is non-final.						
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Dispositi	on of Claims							
5)□ 6)⊠ 7)□	 ✓ Claim(s) 1-23 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. ☐ Claim(s) is/are allowed. ✓ Claim(s) 1-23 is/are rejected. ☐ Claim(s) is/are objected to. 							
Applicati	on Papers							
9)[The specification is objected to by the Exami	ner.						
10)	The drawing(s) filed on is/are: a)☐ ad	ccepted or b) objected to by the	Examiner.					
	Applicant may not request that any objection to the							
11)	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.							
Priority under 35 U.S.C. § 119								
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 								
Attachment(s)								
	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948)	4) Interview Summary Paper No(s)/Mail D						
3) 🛛 Inform	te of Dransperson's Patent Drawing Review (PTO-945) mation Disclosure Statement(s) (PTO-1449 or PTO/SB/0 r No(s)/Mail Date <u>06/24/2003</u> .		Patent Application (PTO-152)					

DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.
- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 2. Claims 1 and 8-14 are rejected under 35 U.S.C. 102(b) as being anticipated by U.S. Patent No. 5,930,655 (Cooney, III et al.) ("Cooney").

Cooney discloses a process to denude fluorine form a dielectric layer the process comprising after the CMP step of a metal and fluorine-containing dielectric wire structure (Fig. 3), generating atomic hydrogen species and exposing the fluorine-containing dielectric to the atomic hydrogen species so as to lower the amount of fluorine from the dielectric material. (col. 6, lines 35-45) The atomic hydrogen species are generated via a plasma or heating process in a furnace wherein a hydrogen-bearing compound such as hydrogen or hydrogen and an inert gas is used. (col. 6, lines 35-44). The metal layer may comprise copper. (col. 3, lines 35-45). The fluorine-containing dielectric, such as SiOF, is completely denuded of fluorine. (col. 5, lines 22-28 and col. 6, lines 59-62).

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3. Claims 15-16 and 21-23 are rejected under 35 U.S.C. 102(e) as being anticipated by U.S. Patent No. 6,433,432 B2 (Shimizu).

Shimizu discloses a process to form a wiring structure comprising a copper conductor and a fluorine-containing dielectric wherein the fluorine-containing layer (item 5) is deposited and patterned to form vias that are to be filled with copper material (item 9) and planarized to form damascene structures (Fig. 3C-F), forming a plasma from a hydrogen bearing gas such as ammonia to generate atomic hydrogen species and exposing the fluorine-containing dielectric to the hydrogen species thereby removing the fluorine from the surface of the fluorine-containing material. (Fig. 3F and col. 5, lines 1-10).

Claim Rejections - 35 USC § 103

- 4. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 5. Claims 2-7 are rejected under 35 U.S.C. 103(a) as being unpatentable over U.S. Patent No. 5,930,655 (Cooney, III et al.) ("Cooney").

As stated in paragraph 2, all the limitations of these claims have been met except for specifying that the fluorine is removed in at least about 700 angstroms or less or equal to 20 percent of the dielectric layer thickness.

While Cooney does not specify the thickness of the dielectric from which the fluorine is removed such a limitation would be obvious to one with ordinary skill in the

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specific art since such a variation would only require a mere change in size and a change in size is generally recognized as being within the level of ordinary skill int eh art. *In re Rose*, 105 SUPQ 237 (CCPA 1955).

6. Claims 17-20 are rejected under 35 U.S.C. 103(a) as being unpatentable over U.S. Patent No. 6,433,432 B2 (Shimizu).

As stated in paragraph 3, all the limitations of these claims have been met except for specifying that the fluorine is removed in at least about 700 angstroms or less or equal to 20 percent of the dielectric layer thickness.

While Cooney does not specify the thickness of the dielectric from which the fluorine is removed such a limitation would be obvious to one with ordinary skill in the specific art since such a variation would only require a mere change in size and a change in size is generally recognized as being within the level of ordinary skill int eh art. *In re Rose*, 105 SUPQ 237 (CCPA 1955).

Conclusion

7. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Renzo Rocchegiani whose telephone number is (571) 272-1904. The examiner can normally be reached on Monday through Friday from 8:30 am to 4:30 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Smith, can be reached at (571) 272-1907. The fax phone number for the organization where this application or proceeding is assigned is (703) 872-9306.

RNR

February 12, 2004

MAITHEW SMITH SUPERVISORY PATENT EXAMINER TECHNOLOGY CENTER 2800